Aharon Inspektor is an adjunct professor in the Department of Materials Science and Engineering at Carnegie Mellon University, Pittsburgh PA, USA. Aharon received his doctor degree in physical chemistry from the Technion Israel Institute of Technology, Israel, focusing on plasma-surface interactions and plasma assisted deposition processes. Prior to joining the department, Aharon served as a senior scientist and products development lead at Kennametal, Inc., guiding the development of new tools, novel surface technologies and coatings. His tea

m earned several industry awards including 2012 KVBS Award for Product Development and Technical Excellence, 2009 Innovator of the Year Award, 2004 KVBS Millennium Award for Technical Excellence, and two Carnegie CST Awards: PVD Nanolayer Technology (2007) and Diamond Technology (1997). Aharon has co-authored over 50 technical peer reviewed papers, invited talks, and patents. He served on the executive board of the Advanced Surface Engineering division of the American Vacuum Society and chaired the division between 2002 and 2003. He served on the editorial boards of *Surface and Coating Technology* from Elsevier; *Journal of Advanced Materials and Manufacturing Process* from Marcel Dekker, Inc.; and *Journal of Adhesion Science* from Technology VSP, the Netherland. He has a special interest in fundamental aspects of plasma-surface interaction, in industrial deposition process and in the applications of surface engineering in manufacturing, aerospace, and automotive industries.